VE320 – Summer 2023

Introduction to Semiconductor Devices

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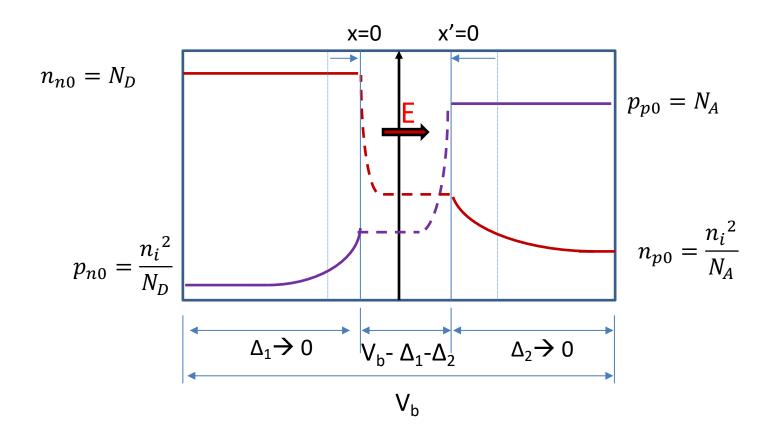
Chapter 8 The pn Junction Diode

Outline

8.1 pn junction current

- 8.2 Generation-recombination currents
- 8.3 High-injection levels
- 8.4 A few more points on pn junctions (not in the textbook)

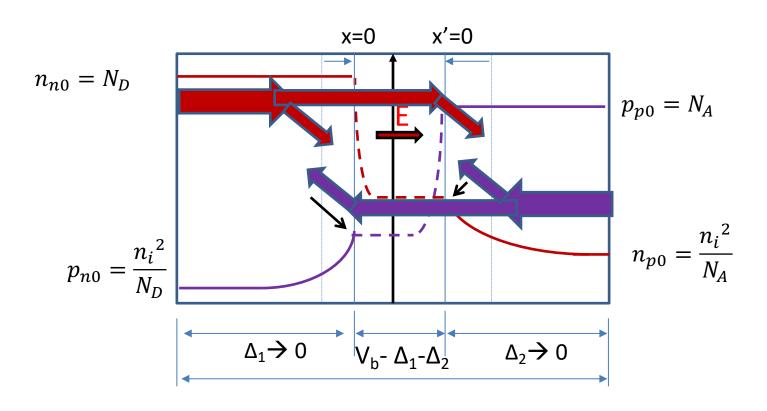
8.0 The logic behind the way to derive current



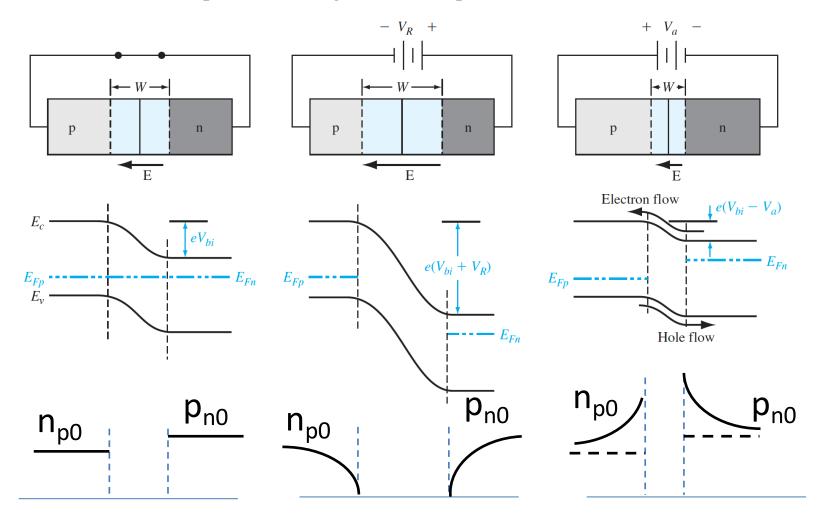
8.0 The logic behind the way to derive current

Total current I_t is uniform at every x

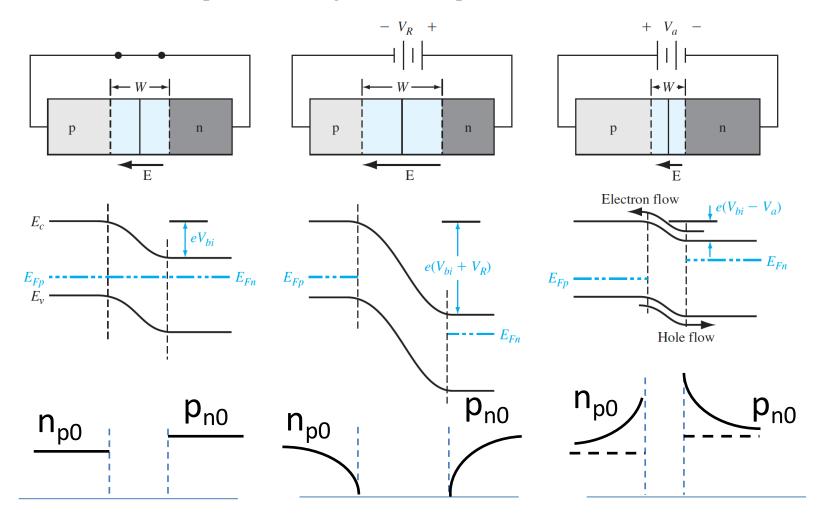
$$I_t = I_n (x=0) + I_h (x=0) = I_n (x'=0) + I_h (x'=0)$$



Qualitative Description of Charge Flow in a pn Junction



Qualitative Description of Charge Flow in a pn Junction

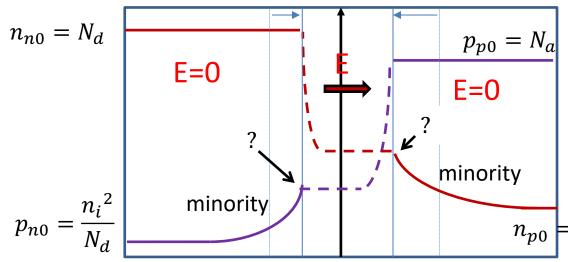


Goal: to find the analytical expression of current

$$\frac{\partial n}{\partial t} = D_n \frac{\partial^2 n}{\partial x^2} + \mu_n E \frac{\partial n}{\partial x} + n \mu_n \frac{\partial E}{\partial x} - \frac{\Delta n}{\tau} + G_{ex}$$

$$\frac{\partial p}{\partial t} = D_p \frac{\partial^2 p}{\partial x^2} - \mu_p E \frac{\partial p}{\partial x} - p \mu_p \frac{\partial E}{\partial x} - \frac{\Delta p}{\tau} + G_{ex}$$

holes as minority



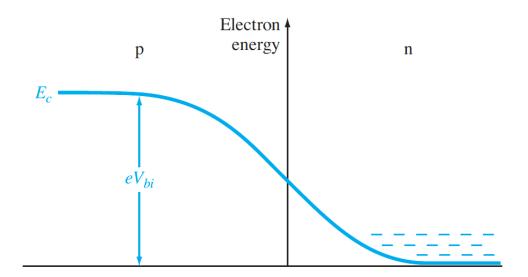
Electrons as minority

- How to simplify?
- Boundary condition?
- how to get total current from minority currents?

$$=\frac{n_i^2}{N_a}$$

Assumptions of an ideal PN junction

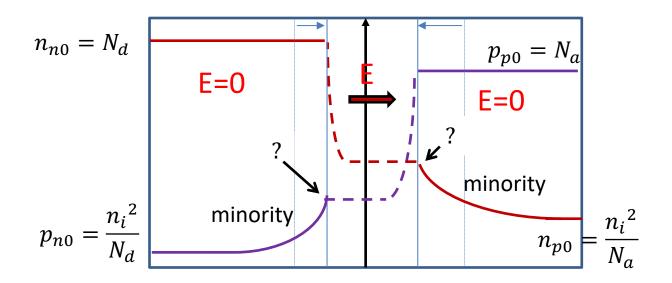
- 1. The abrupt depletion layer approximation applies. The space charge regions have abrupt boundaries, and the semiconductor is neutral outside of the depletion region.
- 2. The Maxwell–Boltzmann approximation applies to carrier statistics.
- **3.** The concepts of low injection and complete ionization apply.
- **4a.** The total current is a constant throughout the entire pn structure.
- **4b.** The individual electron and hole currents are continuous functions through the pn structure.
- **4c.** The individual electron and hole currents are constant throughout the depletion region.



$$V_{bi} = V_t \ln \left(\frac{N_a N_d}{n_i^2} \right)$$

$$n_{p0} = n_{n0} \exp\left(\frac{-eV_{bi}}{kT}\right)$$

$$p_{n0} = p_{p0} exp\left(\frac{-eV_{bi}}{kT}\right) \qquad n_{p0} = n_{n0} \exp\left(\frac{-eV_{bi}}{kT}\right)$$

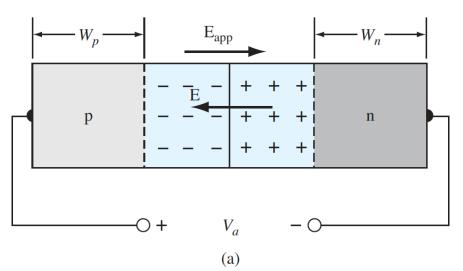


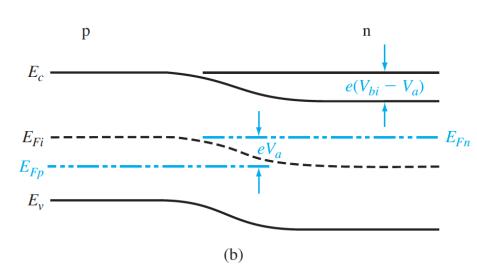
$$p_{n0} = p_{p0} exp\left(\frac{-eV_{bi}}{kT}\right)$$

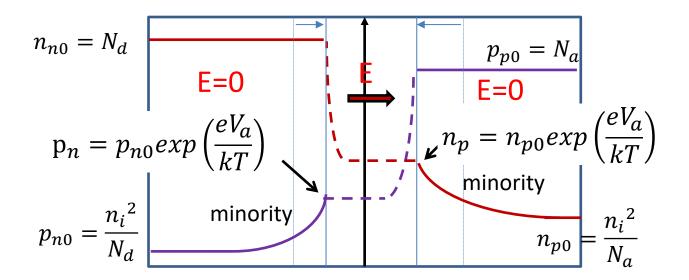
$$n_{p0} = n_{n0} \exp\left(\frac{-eV_{bi}}{kT}\right)$$

$$p_{n} = p_{p0} exp\left(\frac{-e(V_{bi} - V_{a})}{kT}\right) = p_{n0} exp\left(\frac{eV_{a}}{kT}\right)$$

$$n_{p} = n_{p0} exp\left(\frac{eV_{a}}{kT}\right)$$





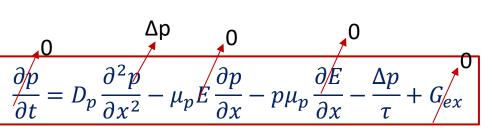


Check your understanding

Problem Example #1

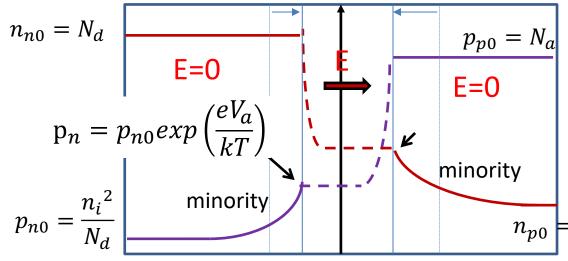
Consider a silicon pn junction at T = 300K. Assume the doping concentration in the n region is $N_d = 10^{16}$ cm⁻³ and the doping concentration in the p region is $N_a = 6 \times 10^{15}$ cm⁻³. Assume a forward bias of 0.6V is applied to the pn junction. Calculate the minority concentration at the edge of the depletion region.

Minority carrier distribution



$$D_p \frac{\partial^2 \Delta p}{\partial x^2} - \frac{\Delta p}{\tau} = 0$$

holes as minority



- How to simplify?
- Boundary condition?
- how to get total current from minority currents?

$$=\frac{n_i^2}{N_a}$$

$$\delta p_n(x) = p_n(x) - p_{n0} = Ae^{x/L_p} + Be^{-x/L_p} \quad (x \le -x_p)$$

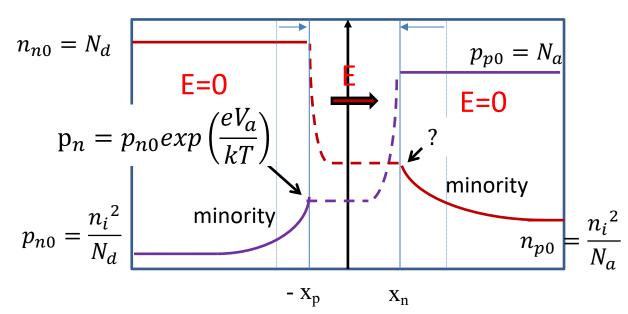
$$\delta n_p(x) = n_p(x) - n_{p0} = Ce^{x/L_n} + De^{-x/L_n} \quad (x \ge x_n)$$

$$p_n(x_n) = p_{n0} \exp\left(\frac{eV_a}{kT}\right)$$

$$n_p(-x_p) = n_{p0} \exp\left(\frac{eV_a}{kT}\right)$$

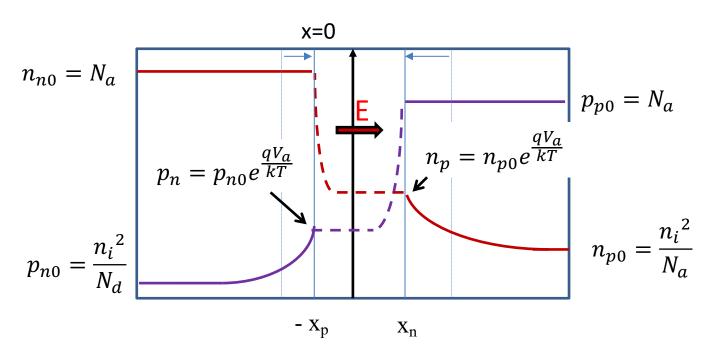
$$p_n(x \to +\infty) = p_{n0}$$

$$n_p(x \to -\infty) = n_{p0}$$



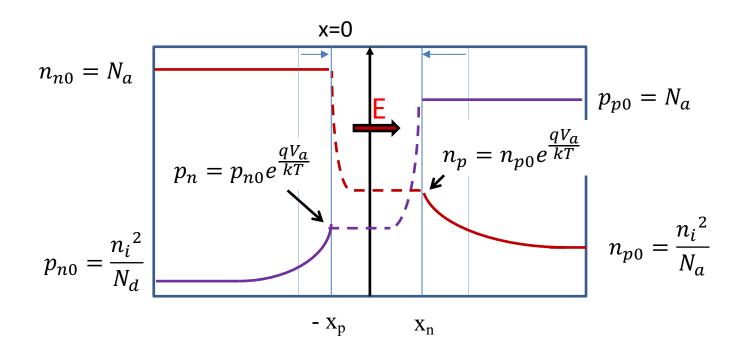
$$\Rightarrow \Delta p = p_n(x) - p_{n0} = p_{n0} (e^{\frac{qV_a}{kT}} - 1)e^{(x+x_p)/L_p}$$

$$\Rightarrow \Delta n = n_p(x) - n_{p0} = n_{p0} (e^{\frac{qV_a}{kT}} - 1)e^{(x_n - x)/L_n}$$



$$p = p_o + \delta p = n_i \exp\left(\frac{E_{Fi} - E_{Fp}}{kT}\right)$$

$$n = n_o + \delta n = n_i \exp\left(\frac{E_{Fn} - E_{Fi}}{kT}\right)$$



$$p = p_o + \delta p = n_i \exp\left(\frac{E_{Fi} - E_{Fp}}{kT}\right) \qquad n = n_o + \delta n = n_i \exp\left(\frac{E_{Fn} - E_{Fi}}{kT}\right)$$

$$np = n_i^2 \exp\left(\frac{E_{Fn} - E_{Fp}}{kT}\right)$$

$$E_C$$

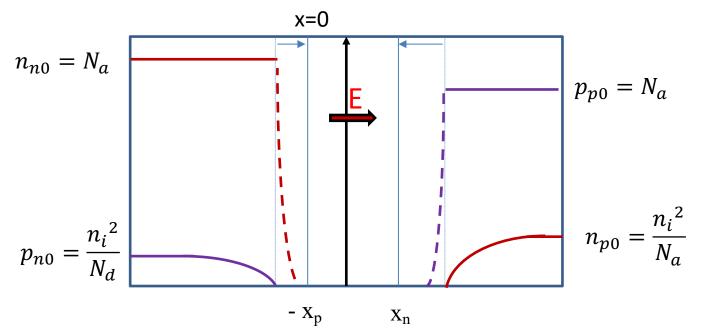
$$E_{Fn}$$

$$E_{Fi}$$

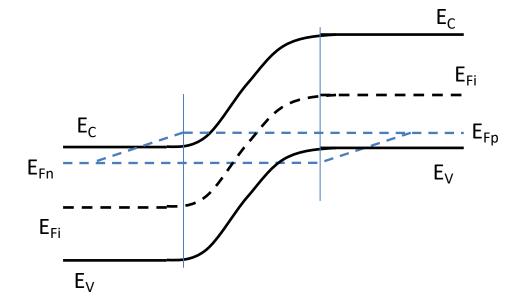
$$E_{Fi}$$

$$E_{V}$$

$$p = p_o + \delta p = n_i \exp\left(\frac{E_{Fi} - E_{Fp}}{kT}\right) \qquad n = n_o + \delta n = n_i \exp\left(\frac{E_{Fn} - E_{Fi}}{kT}\right)$$
$$np = n_i^2 \exp\left(\frac{E_{Fn} - E_{Fp}}{kT}\right)$$

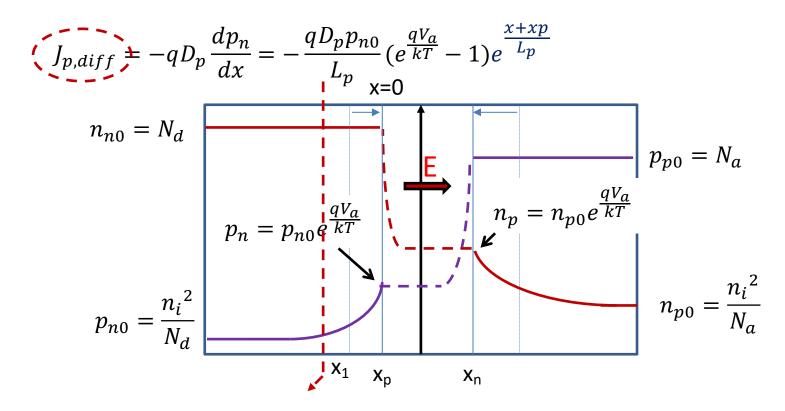


$$p = p_o + \delta p = n_i \exp\left(\frac{E_{Fi} - E_{Fp}}{kT}\right) \qquad n = n_o + \delta n = n_i \exp\left(\frac{E_{Fn} - E_{Fi}}{kT}\right)$$
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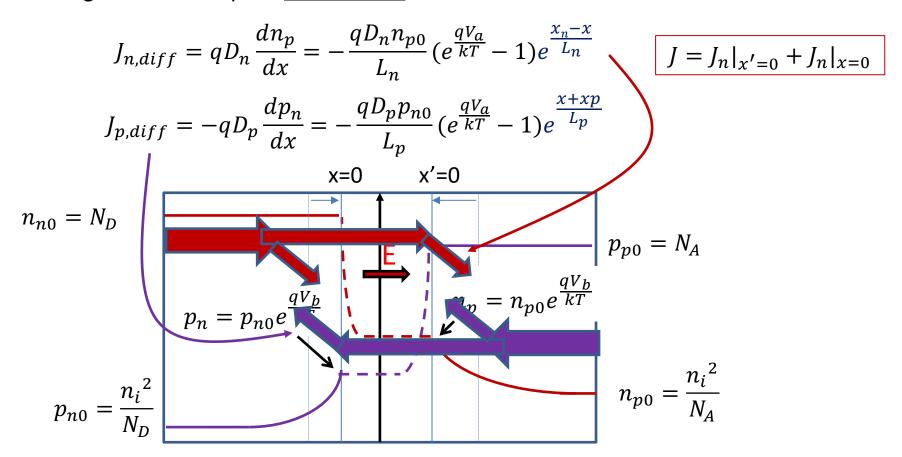


charge carrier transport: <u>forward bias</u>

$$J_{n,diff} = qD_n \frac{dn_p}{dx} = -\frac{qD_n n_{p0}}{L_n} (e^{\frac{qV_a}{kT}} - 1)e^{\frac{x_n - x}{L_n}}$$

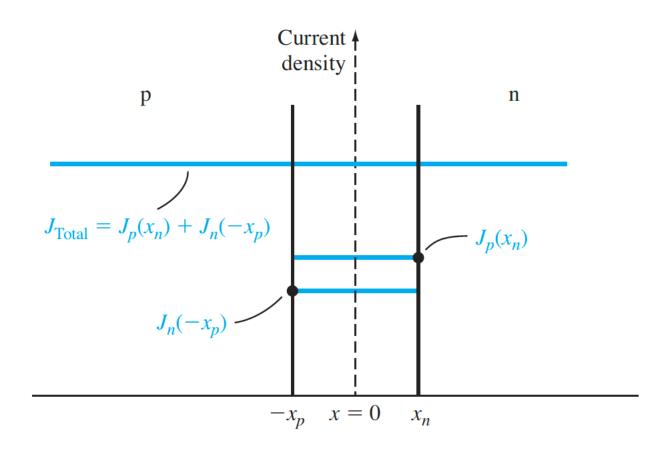


charge carrier transport: <u>forward bias</u>



Assumption: No recombination-generation in depletion region.

• Ideal pn junction current



Assumption: No recombination-generation in depletion region.

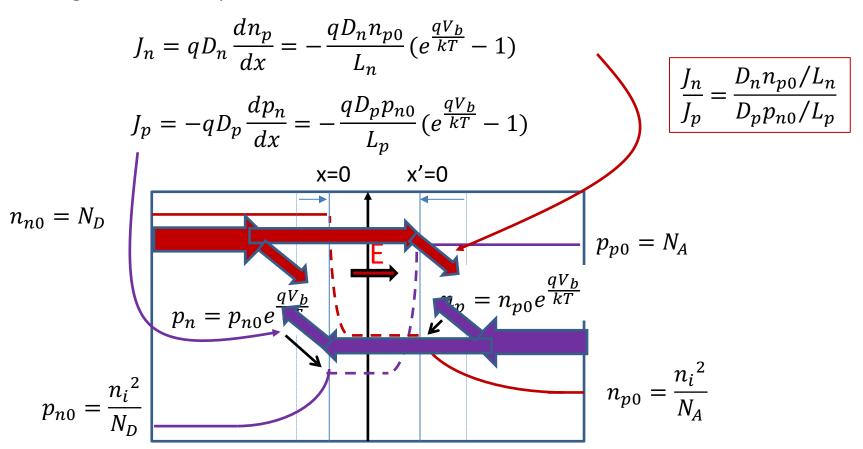
Ideal pn junction current

$$J = J_n|_{x'=0} + J_n|_{x=0}$$

$$J = J_s(e^{\frac{qV_b}{kT}} - 1)$$

$$J_{s} = \frac{qD_{n}n_{p0}}{L_{n}} + \frac{qD_{p}p_{n0}}{L_{p}}$$

charge carrier transport: <u>forward bias: current ratio</u>



Assumption: No recombination-generation in depletion region.

charge carrier transport: <u>reverse bias</u>

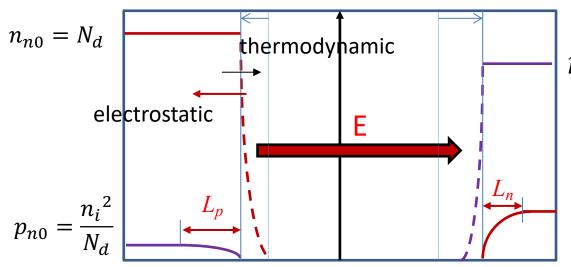
$$J_n = qD_n \frac{dn_p}{dx} = \frac{qD_n n_{p0}}{L_n}$$

$$J_p = -qD_p \frac{dp_n}{dx} = \frac{qD_p p_{n0}}{L_p}$$

$$J = J_n|_{x'=0} + J_n|_{x=0}$$

$$J = J_s \left(e^{\frac{qV_b}{kT}} - 1 \right) = -J_s$$

$$J_s = \frac{qD_n n_{p0}}{L_n} + \frac{qD_p p_{n0}}{L_p}$$

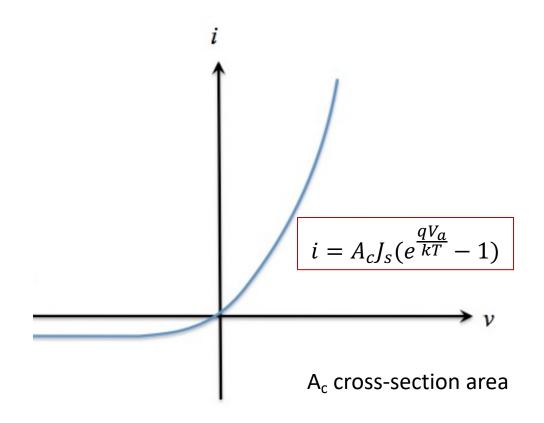


$$p_{p0} = N_a$$

$$n_{p0} = \frac{n_i^2}{N_a}$$

Assumption: No recombination-generation in depletion region.

charge carrier transport: <u>forward bias</u>



$$J = J_n|_{x'=0} + J_n|_{x=0}$$

$$J = J_s(e^{\frac{qV_b}{kT}} - 1)$$

$$J_s = \frac{qD_n n_{p0}}{L_n} + \frac{qD_p p_{n0}}{L_p}$$

Check your understanding

Problem Example #2

Given the following parameters in a silicon pn junction, determine the ideal reverse-saturation current density of this pn junction at 300K.

$$N_a = N_d = 10^{16} \text{ cm}^{-3}$$
 $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$ $D_n = 25 \text{ cm}^2/\text{s}$ $\tau_{p0} = \tau_{n0} = 5 \times 10^{-7} \text{ s}$ $\tau_{p0} = 10 \text{ cm}^2/\text{s}$ $\epsilon_r = 11.7$

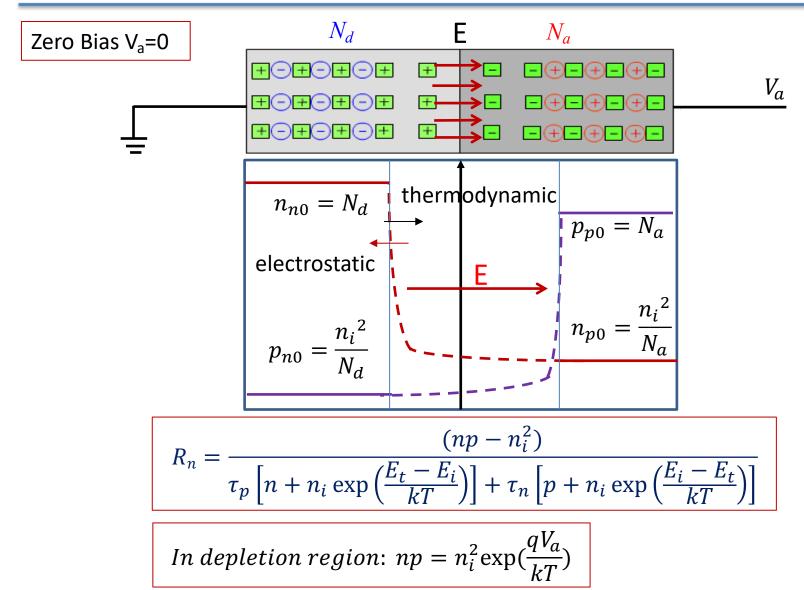
Outline

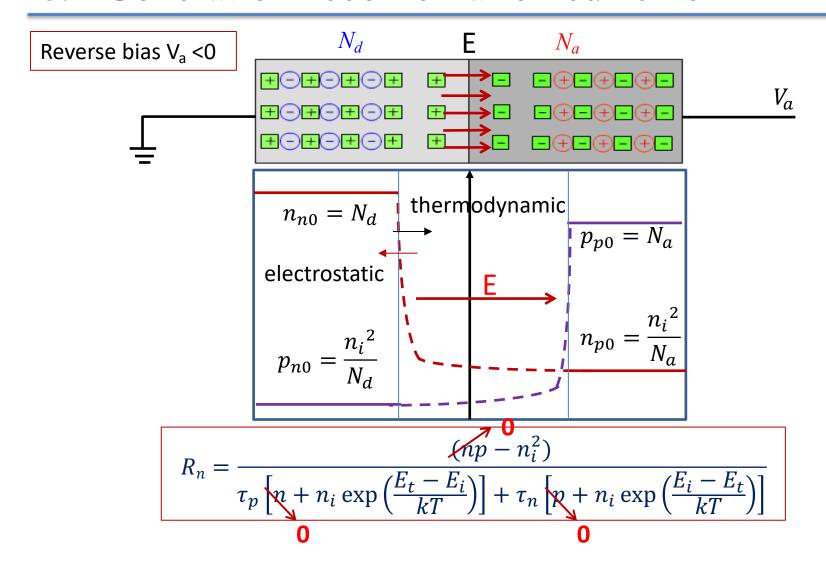
8.1 pn junction current

8.2 Generation-recombination currents

8.3 High-injection levels

8.4 A few more points on pn junctions (not in the textbook)





Reverse bias V_a <0

To simplify the calculation, we assume

$$E_t = E_i$$
, $\tau_n = \tau_p = \tau$

$$R_n = \frac{-n_i}{2\tau} = -G_0$$

$$R_{n} = \frac{(np - n_{i}^{2})}{\tau_{p} \left[n + n_{i} \exp\left(\frac{E_{t} - E_{i}}{kT}\right) \right] + \tau_{n} \left[p + n_{i} \exp\left(\frac{E_{i} - E_{t}}{kT}\right) \right]}$$

Reverse bias V_a <0

To simplify the calculation, we assume

$$E_t = E_i$$
, $\tau_n = \tau_p = \tau$

$$R_n = \frac{-n_i}{2\tau} = -G_0$$

Current density from G-R in the depletion region:

$$J_r = \int_0^W qG_0 dx = \frac{qWn_i}{2\tau}$$

$$R_{n} = \frac{(np - n_{i}^{2})}{\tau_{p} \left[n + n_{i} \exp\left(\frac{E_{t} - E_{i}}{kT}\right) \right] + \tau_{n} \left[p + n_{i} \exp\left(\frac{E_{i} - E_{t}}{kT}\right) \right]}$$

Reverse bias V_a <0

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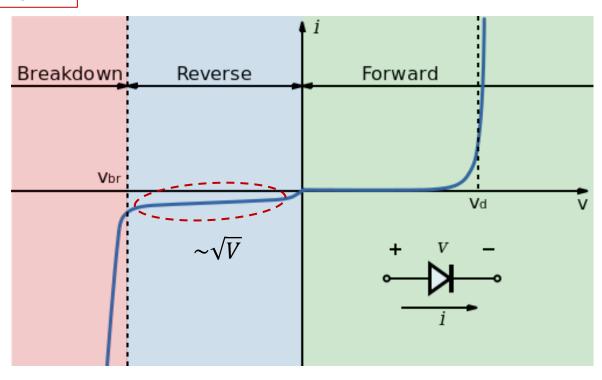
Current density from G-R in the depletion region:

$$J_r = \int_0^W qG_0 dx = \frac{qWn_i}{2\tau}$$

$$W = a + b = \sqrt{\frac{2\varepsilon(V_{bi} - V_a)}{q} \frac{N_d + N_a}{N_a N_d}}$$

$$R_{n} = \frac{(np - n_{i}^{2})}{\tau_{p} \left[n + n_{i} \exp\left(\frac{E_{t} - E_{i}}{kT}\right) \right] + \tau_{n} \left[p + n_{i} \exp\left(\frac{E_{i} - E_{t}}{kT}\right) \right]}$$

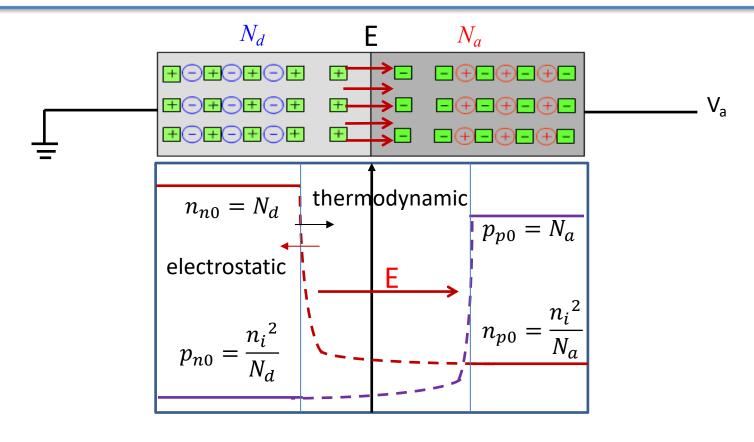
Reverse bias V_a <0



Current density from G-R in the depletion region:

$$J_r = \int_0^W qGdx = \frac{qWn_i}{2\tau}$$

$$W = a + b = \sqrt{\frac{2\varepsilon(V_{bi} - V_a)}{q} \frac{N_d + N_a}{N_a N_d}}$$



In depletion region: $np = n_i^2 \exp(\frac{qV_a}{kT})$

To simplify the calculation, we assume

$$E_t = E_i$$
, $\tau_n = \tau_p = \tau$

$$R_n = \frac{np - n_i^2}{\tau(n + p + 2n_i)}$$

When n=p, U reaches its max value.

$$R_{n,max} = \frac{np - n_i^2}{\tau \left[n_i \exp(\frac{qV_a}{2kT}) + n_i \exp(\frac{qV_a}{2kT}) + 2n_i \right]} = \frac{n_i \left[\exp\left(\frac{qV_a}{kT}\right) - 1 \right]}{2\tau \left[\exp\left(\frac{qV_a}{2kT}\right) + 1 \right]}$$

$$= \frac{n_i \left[\exp\left(\frac{qV_a}{2kT}\right) - 1 \right]}{2\tau}$$

In depletion region:
$$np = n_i^2 \exp(\frac{qV_a}{kT})$$

$$R_{n,max} = \frac{n_i}{2\tau} \left[\exp\left(\frac{qV_a}{2kT}\right) - 1 \right]$$

Current density from G-R in the depletion region:

$$J_r = \int_0^W q R_{n,max} dx = \frac{qW n_i}{2\tau} \left[\exp\left(\frac{qV_a}{2kT}\right) - 1 \right]$$

For a non-ideal pn junction, the total current density:

$$J = J_F + J_r = J_s \left[\exp\left(\frac{qV_a}{kT}\right) - 1 \right] + \frac{qWn_i}{2\tau} \left[\exp\left(\frac{qV_a}{2kT}\right) - 1 \right]$$

$$J = J_F + J_r = J_s \left[\exp\left(\frac{qV_a}{kT}\right) - 1 \right] + \frac{qWn_i}{2\tau} \left[\exp\left(\frac{qV_a}{2kT}\right) - 1 \right]$$

Forward bias V > 3kT/q = 0.078V:

$$J = J_F + J_r = J_s \exp\left(\frac{qV_a}{kT}\right) + \frac{qWn_i}{2\tau} \exp\left(\frac{qV_a}{2kT}\right) = J_0 \exp\left(\frac{qV_a}{nkT}\right)$$
the ideality factor

$$J = J_F + J_r = J_s \left[\exp\left(\frac{qV_a}{kT}\right) - 1 \right] + \frac{qWn_i}{2\tau} \left[\exp\left(\frac{qV_a}{2kT}\right) - 1 \right]$$

Forward bias V > 3kT/q = 0.078V:

$$J = J_F + J_r = J_S \exp\left(\frac{qV_a}{kT}\right) + \frac{qWn_i}{2\tau} \exp\left(\frac{qV_a}{2kT}\right) = J_0 \exp\left(\frac{qV_a}{nkT}\right)$$
the ideality factor

Reverse bias:

$$J_{0} = -J_{s} - \frac{qWn_{i}}{2\tau} = -\left(\frac{qD_{n}n_{p0}}{L_{n}} + \frac{qD_{p}p_{n0}}{L_{p}}\right) - \frac{qWn_{i}}{2\tau}$$

Check your understanding

Problem Example #3

An n-type semiconductor ($10^{17} cm^{-3}$) is in contact with another p-type semicondcutor ($10^{17} cm^{-3}$). Suppose a silicon PN junction has defects located at the middle of the bangap. The defect concentration is $10^{16} cm^{-3}$ and the capture rate C_n and C_p for electrons and holes are $10^{-10} cm^{-3}/s$. Find the leakage current of the Si PN junction if the pn junction is reverse biased at 1V (V_R =1V).



Depletion region

$$N_t = 10^{16} \text{ cm}^{-3}$$

 $C_n = C_p = 10^{-10} \text{ cm}^{-3}/\text{s}$

Outline

- 8.1 pn junction current
- 8.2 Generation-recombination currents
- 8.3 High-injection levels
- 8.4 A few more points on pn junctions (not in the textbook)

8.3 High inject level

$$J = J_F + J_r = J_s \exp\left(\frac{qV_a}{kT}\right) + \frac{qWn_i}{2\tau} \exp\left(\frac{qV_a}{2kT}\right) = J_0 \exp\left(\frac{qV_a}{nkT}\right)$$

e-h pairs recombine in the depletion region $\frac{1}{\text{Ideal diffusion current}}, J_D \\ \text{(slope} = 1) \\ \text{(slope} = \frac{1}{2})$

 $\frac{eV_a}{kT}$

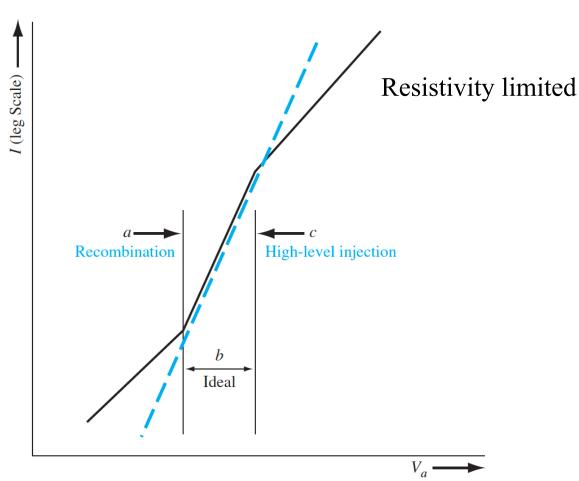




 $\ln (J_s)$

8.3 High inject level

$$J = J_F + J_r = J_S \exp\left(\frac{qV_a}{kT}\right) + \frac{qWn_i}{2\tau} \exp\left(\frac{qV_a}{2kT}\right) = J_0 \exp\left(\frac{qV_a}{nkT}\right)$$



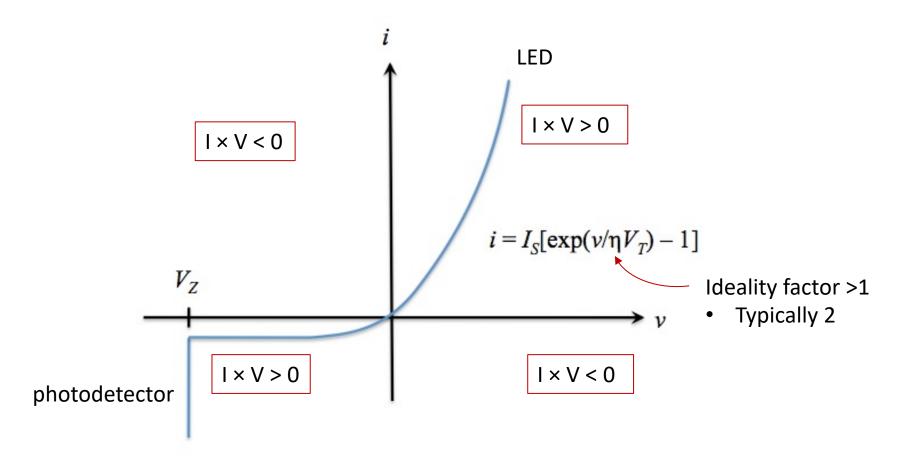


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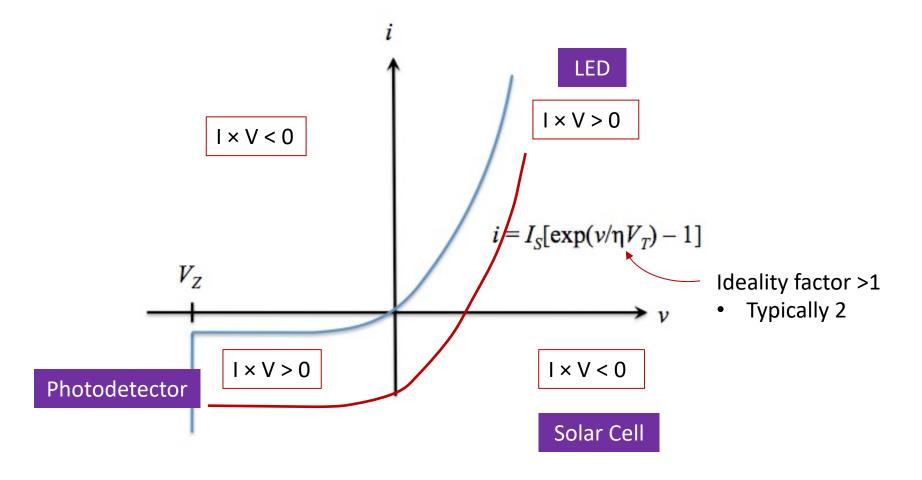
8.4 A few points about pn junction

Energy consumption:



8.4 A few points about pn junction

Energy consumption:



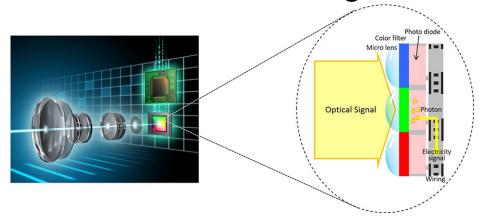
Introduction to semiconductor devices

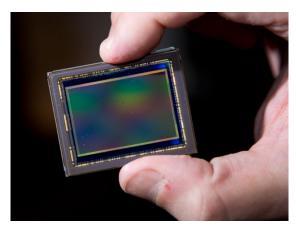


Light emitting diodes

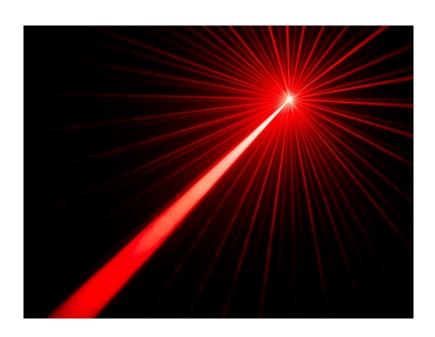
Cold light source

Photodetector: CMOS image sensor





Introduction to semiconductor devices



Semiconductor lasers



Solar cells